Biochip and Microarrays for Rapid Assessment of New Chemicals

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Project Objectives and Impact

- Rapid assessment of chemicals and process chemistries
- Important for both chemical suppliers (starting materials) and equipment suppliers/end users (for process-generated byproducts, interactions of multiple chemicals, proprietary chemistries in R/D stage, etc.)
- ➤ A first step towards an on-line ESH monitor.



Introduction: Microarray Measurement



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Introduction: Power of the Approach







Secreted Cell Products 1. Secreted Cell Products 1.

2.



Cells are engineered to secrete the enzyme alkaline phosphatase in response to toxic insult



Cells are arrayed onto biochip electrodes, which double as photodetectors

3.

Biochip is exposed to test chemical of interest in a matrix with two indicator chemicals. Alkaline phosphatase (AP) converts one chemical into an electron donor (measured electrochemically) and the other into a fluorophore (measured photometrically).



Introduction: CMOS Substrates

Why CMOS?

- Complementary Metal Oxide Semiconductor (CMOS)
- Replace "dumb" glass substrate with "smart" substrate capable of selfinterrogation
- Introduce electronic control to printing, hybridization, and detection
- Couple advances in microelectronics to advances in microarrays



Why Miniaturize?

- 1. Reduced Cost
- 2. Reduced Cost
- 3. Reduced Cost
- 4. Increased Reliability
- 5. Increased Functionality
- 6. Reduced Size

MultiSensor Fusion

A Single Hybridization Site



CMOS BioChip

- Electric field directed binding
- Hybridization site monitored with capacitance
- Electrochemical analysis at each pad
- On chip photodetectors
- Data transfer from chip in digital form for bioinformatics

Indium Tin Oxide (ITO) (Transparent and Conductive)

- Oxygen flow rate between 0 20 sccm
 - Best results around 20 sccm
- Deposition rate 28.6-33.3 Å / min
- Higher resistance values
 - Between 184 2 x $10^7 \Omega$
- Vacuum anneal temperature 225° C for 2 hr



Introduction: E-Field Directed DNA

Confocal Image of bound DNA



Simulated E-field



Grid for Finite Difference Method



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Hybridization Site Preparation

Capacitance Measurements

- Measured capacitance is used to monitor oxide formation and surface conditions at hybridization site.
- Capacitance measurements have been used to determine surface coverage of single stranded DNA to levels of (1-10) x 10¹² molecules/cm²
 A. Steel, et. al. Anal. Chem. 1998 p.4670
- Human chronic gonadotropin hormone have detection limits of 15 x 10⁻¹⁵ M C. Berggren, and G. Johansson, Anal. Chem. 1997 p. 3651



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Diffusion

• 1-D Finite Difference Equation: $C(x_0, t + \Delta t) = C(x_0, t) + \frac{D\Delta t}{\Delta h 2} (C(x_0 + \Delta h, t) - 2C(x_0, t) + C(x_0 - \Delta h, t))$

• **1-D Actual Value Equation:** $C(x_0, t) = C_{initial} \left(1 - erfc \left(\frac{x_0}{2\sqrt{Dt}} \right) \right)$

Potential at the electrode



Cyclic Voltammetry Currents



Current Plots for different sweep rates for t = 30 sec NSF/SRC Engineering Research Center for Environmentally Benign Semiconductor Manufacturing

Indium Tin Oxide (ITO)

Fabrication 20 Sample 1 15 -Sample 2 10 5 (MA) i 0. -5 - 10 4L TESE 10/18 - 15 1200 1000 800 600 400 200 0 -200 mV vs. Ag/AgCI 100 80 Transmission (%) Sample 73 60 Sample 74 Sample 75 Sample 76 40 20 0∟ 300 400 500 600 700 800 Wavelength (nm)

Characterization

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CMOS Photodetector



See Class Notes OPTI 580 Microphotonics Instructor: Prof. D. L. Mathine

Double Fabry-Perot Cavity Filter



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Characterization of CMOS chip for Chemical Analysis

Design



Experimental Test Bed







Future Plans

Next year plan:

•Engineer alkaline-phosphatase toxicity reporting cells

•Design next generation of CMOS biochip for biologically based electrooptical assays

•Assess electrochemical and photometric detection limits of system

•Optimize biochip surface chemistry

Long-Term Plans:

•Low-cost sensors for use by chemical suppliers (responsible for starting feed materials) and process engineers and ESH professionals (responsible for evaluation of new chemistries during and after the processing cycle)

•New generation of highly selective and inexpensive sensors for real-time and online monitoring in the manufacturing site.